PATENT COOPERATION TREATY

PCT

NOTIFICATION OF ELECTION

(PCT Rule 61.2)

From the INTERNATIONAL BUREAU

To:

Commissioner
US Department of Commerce
United States Patent and Trademark
Office, PCT
2011 South Clark Place Room
CP2/5C24
Arlington, VA 22202
ETATS-UNIS D'AMERIQUE

Applicant's or agent's file reference

Date of mailing (day/month/year) 18 May 2001 (18.05.01)

in its capacity as elected Office

International application No. PCT/GB00/03603

International filing date (day/month/year)
20 September 2000 (20.09.00)

N76945A PEJ

Priority date (day/month/year)
20 September 1999 (20.09.99)

Applicant

TURBERFIELD, Andrew, Jonathan et al

1.	The designated Office is hereby notified of its election made:
	X in the demand filed with the International Preliminary Examining Authority on:
	16 March 2001 (16.03.01)
	in a notice effecting later election filed with the International Bureau on:
2.	The election X was
	was not
	made before the expiration of 19 months from the priority date or, where Rule 32 applies, within the time limit under Rule 32.2(b).

The International Bureau of WIPO 34, chemin des Colombettes 1211 Geneva 20, Switzerland Authorized officer

Olivia TEFY

Telephone No.: (41-22) 338.83.38

Facsimile No.: (41-22) 740.14.35

RMING THE APPLICANT OF THE

NOTICE INFORMING THE APPLICANT OF THE COMMUNICATION OF THE INTERNATIONAL APPLICATION TO THE DESIGNATED OFFICES

(PCT Rule 47.1(c), first sentence)

From the INTERNATIONAL BUREAU

To: ELLIS-JONES, Patrick, George,

Armine J.A. Kemp & Co. 14 South Square

Gray's Inn London WC1R 5LX ROYAUME-UNI J. A. KEN

REC'D - 9 AFR 2001

. . .

Date of mailing (day/month/year) 29 March 2001 (29.03.01)

Applicant's or agent's file reference

N76945A PEJ

IMPORTANT NOTICE

International application No. PCT/GB00/03603

International filing date (day/month/year) 20 September 2000 (20.09.00)

Priority date (day/month/year)

20 September 1999 (20.09.99)

Applicant

ISIS INNOVATION LIMITED et al

 Notice is hereby given that the international Bureau has communicated, as provided in Article 20, the international application to the following designated Offices on the date indicated above as the date of mailing of this Notice: AU,KP,KR,US

In accordance with Rule 47.1(c), third sentence, those Offices will accept the present Notice as conclusive evidence that the communication of the international application has duly taken place on the date of mailing indicated above and no copy of the international application is required to be furnished by the applicant to the designated Office(s).

2. The following designated Offices have waived the requirement for such a communication at this time:

AE,AG,AL,AM,AP,AT,AZ,BA,BB,BG,BR,BY,BZ,CA,CH,CN,CR,CU,CZ,DE,DK,DM,DZ,EA,EE,EP,ES,FI,GB,GD,GE,GH,GM,HR,HU,ID,IL,IN,IS,JP,KE,KG,KZ,LC,LK,LR,LS,LT,LU,LV,MA,MD,MG,MK,MN,MW,MX,MZ,NO,NZ,OA,PL,PT,RO,RU,SD,SE,SG,SI,SK,SL,TJ,TM,TR,TT,TZ,UA,UG,UZ,VN,YU,The communication will be made to those Offices only upon their request. Furthermore, those Offices do not require the applicant to furnish a copy of the international application (Rule 49.1(a-bis)).

3. Enclosed with this Notice is a copy of the international application as published by the International Bureau on 29 March 2001 (29.03.01) under No. WO 01/22133

REMINDER REGARDING CHAPTER II (Article 31(2)(a) and Rule 54.2)

If the applicant wishes to postpone entry into the national phase until 30 months (or later in some Offices) from the priority date, a demand for international preliminary examination must be filed with the competent International Preliminary Examining Authority before the expiration of 19 months from the priority date.

It is the applicant's sole responsibility to monitor the 19-month time limit.

Note that only an applicant who is a national or resident of a PCT Contracting State which is bound by Chapter II has the right to file a demand for international preliminary examination.

REMINDER REGARDING ENTRY INTO THE NATIONAL PHASE (Article 22 or 39(1))

If the applicant wishes to proceed with the international application in the **national phase**, he must, within 20 months or 30 months, or later in some Offices, perform the acts referred to therein before each designated or elected Office.

For further important information on the time limits and acts to be performed for entering the national phase, see the Annex to Form PCT/IB/301 (Notification of Receipt of Record Copy) and Volume II of the PCT Applicant's Guide.

The International Bureau of WIPO 34, chemin des Colombettes 1211 Geneva 20, Switzerland

Authorized officer

J. Zahra

Facsimile No. (41-22) 740.14.35

Telephone No. (41-22) 338.83.38



(PCT Article 18 and Rules 43 and 44)

Applicant's or agent's file reference N76945A PEJ	FOR FURTHER see Notification of (Form PCT/ISA/2)	of Transmittal of International Search Report (20) as well as, where applicable, item 5 below.
International application No.	International filing date (day/month/year)	(Earliest) Priority Date (day/month/year)
PCT/GB 00/03603	20/09/2000	20/09/1999
Applicant ISIS INNOVATION LIMITED		
according to Article 18. A copy is being to This International Search Report consists		
Basis of the report a. With regard to the language, the language in which it was filed, ur	international search was carried out on the balless otherwise indicated under this item.	sis of the international application in the
the international search v Authority (Rule 23.1(b)).	vas carried out on the basis of a translation of	the international application furnished to this
was carried out on the basis of the contained in the internation of the filed together with the internation of the furnished subsequently to the statement that the substant international application.	ne sequence listing: onal application in written form. ernational application in computer readable for o this Authority in written form. o this Authority in computer readble form. absequently furnished written sequence listing of as filed has been furnished.	
Certain claims were for Unity of invention is lace.	und unsearchable (See Box I). cking (see Box II).	
	ubmitted by the applicant. shed by this Authority to read as follows:	
the text has been establi within one month from the	e date of mailing of this international search re	rity as it appears in Box III. The applicant may, eport, submit comments to this Authority.
	olished with the abstract is Figure No.	X None of the figures.
as suggested by the applicant to		Notice of the figures.
because the applicant fa	ned to suggest a figure. In characterizes the invention.	
I Decause this hydre bette	a origination 200 the myonitor.	

International application No. GB 00/03603

Box III TEXT OF THE ABSTRACT (Continuation of item 5 of the first sheet)

Line 8: Line 8:	replace "." with "," after "1000" add "e.g. a glycidyl ether of bisphenol A novolac resin, preferably a SU-8 negative photoresist." after "1000,"

International Application No

B 00/03603

A. CLASSIFICATION OF SUBJECT MATTER IPC 7 G02B6/12 C08I C08L63/00

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

 $\begin{array}{ccc} \text{Minimum documentation searched (classification system followed by classification symbols)} \\ IPC & 7 & G02B & C08L \\ \end{array}$

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

INSPEC, EPO-Internal, CHEM ABS Data

		Relevant to claim No.
Category °	Citation of document, with indication, where appropriate, of the relevant passages	Helevant to claim No.
X	WITZGALL G ET AL: "Single-shot two-photon exposure of commercial photoresist for the production of three-dimensional structures" OPTICS LETTERS, 15 NOV. 1998, USA, vol. 23, no. 22, pages 1745-1747, XP000955303 ISSN: 0146-9592	1-3,8, 10-17, 22,23
Y	page 1745 page 1747, right-hand column/	4-7,9

X Further documents are listed in the continuation of box C.	Patent family members are listed in annex
'A' document defining the general state of the art which is not considered to be of particular relevance 'E' earlier document but published on or after the international filing date 'L' document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) 'O' document referring to an oral disclosure, use, exhibition or other means	 'T' later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention 'X' document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone 'Y' document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art.
P document published prior to the international filing date but later than the priority date claimed	'&' document member of the same patent family
Date of the actual completion of the international search	Date of mailing of the international search report
5 December 2000	21/12/2000
Name and mailing address of the ISA	Authorized officer
European Patent Office. P.B. 5818 Patentlaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040. Tx. 31 651 epo nl. Fax. (+31-70) 340-3016	von Moers, F

1

International Application No
PC 8 00/03603

`atagen; o l	tion) DOCUMENTS CONSIDERED BE RELEVANT Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Category °	Onation of document, with indication, where appropriate, of the relevant passages	Ticlovant to dain 110.
.	LEE K Y ET AL: "Micromachining applications of a high resolution ultrathick photoresist" JOURNAL OF VACUUM SCIENCE & TECHNOLOGY B , NOVDEC. 1995, USA, vol. 13, no. 6, pages 3012-3016, XP002154618 ISSN: 0734-211X page 3012	4-7,9
x	WO 99 09439 A (DENNING ROBERT GORDON;TURBERFIELD ANDREW JONATHAN (GB); ISISINNO) 25 February 1999 (1999-02-25) cited in the application	23
۹ ا	page 10, line 15 -page 15, line 30	1,18-21
P,X	CAMPBELL M ET AL: "Fabrication of photonic crystals for the visible spectrum by holographic lithography" NATURE, 2 MARCH 2000, MACMILLAN MAGAZINES, UK, vol. 404, no. 6773, pages 53-56, XP000961267 ISSN: 0028-0836 the whole document	1-23

1

Information on patent family members

International Application No

PC 8 00/03603

Patent document cited in search report Publication date Patent family member(s) Publication date

WO 9909439 A 25-02-1999 EP 1005661 A 07-06-2000

Applicant's or agent's file reference

Form PCT/IPEA/409 (cover sheet) (January 1994)

REC'D 3 0 JAN 2002

See Notification of Transmittal of International

POT

INTERNATIONAL PRELIMINARY EXAMINATION REPORT

(PCT Article 36 and Rule 70)

N76945A PEJ		FORFURIN	ER ACTION F	Preliminary Examination Report (Form PCT/IPEA/4)	16)
International application No. PCT/GB00/03603		International filing 20/09/2000	g date (day/month/ye	ar) Priority date (day/month/year) 20/09/1999	
Internation G02B6/1		n (IPC) or national classification	and IPC		
Applicant	OVATION I IMITE	-			
	OVATION LIMITE		heen propared by	r this International Preliminary Examining Aut	
		applicant according to Articl		ruis international Freiminary Examining Aut	nority
2. This	REPORT consists o	of a total of 11 sheets, include	ding this cover she	et.	
] b	een amended and a	ecompanied by ANNEXES, it are the basis for this report a Section 607 of the Administ	and/or sheets cont	escription, claims and/or drawings which hav aining rectifications made before this Authorit under the PCT).	e ty
These	e annexes consist o	f a total of sheets.			
3. This r	eport contains indic	ations relating to the following	na items:		
1	Basis of the r ■		ng noms.		
II	☐ Priority	eport			
(1)		nment of opinion with regard	to novelty invent	ive step and industrial applicability	
IV	☐ Lack of unity		i to novelty, invent	ive step and industrial applicability	
V	⊠ Reasoned sta		with regard to nove	elty, inventive step or industrial applicability;	
VI	☐ Certain docu		rotatement		
VII		ts in the international applic	ation		
VIII	_	rvations on the international			
Date of sub-	mission of the demand	I	Date of comp	pletion of this report	
16/03/200)1		28.01.2002		
	nailing address of the i		Authorized o	fficer	5 PATERILAS
<i>)</i>))	European Patent Offi D-80298 Munich Tel. +49 89 2399 - 0		Tissot, L	(No see Co. 16.	
	Fax: +49 89 2399 - 4	465	Telephone N	0. +49 89 2399 2586	10 10 B





International application No. PCT/GB00/03603

l. Basis	of 1	the	re	port	
----------	------	-----	----	------	--

1. With regard to the elements of the international application (Replacement sheets which have been furr the receiving Office in response to an invitation under Article 14 are referred to in this report as "original and are not annexed to this report since they do not contain amendments (Rules 70.16 and 70.17)): Description, pages:			response to an invitation under Article 14 are referred to in this report on "principally still are		
	1-	8	as originally filed		
	CI	aims, No.:			
	1-3	23	as originally filed		
	Dr	awings, sheets:			
	1/	1	as originally filed		
2.	. Wi lan	th regard to the lang guage in which the ir	uage, all the elements marked above were available or furnished to this Authority in the nternational application was filed, unless otherwise indicated under this item.		
	Th	ese elements were a	vailable or furnished to this Authority in the following language: , which is:		
		the language of a ti	ranslation furnished for the purposes of the international search (under Rule 23.1(b)).		
		the language of pul	plication of the international application (under Rule 48.3(b)).		
		the language of a tr 55.2 and/or 55.3).	anslation furnished for the purposes of international preliminary examination (under Rule		
3.	Wit	h regard to any nucl ernational preliminary	eotide and/or amino acid sequence disclosed in the international application, the examination was carried out on the basis of the sequence listing:		
		contained in the inte	ernational application in written form.		
		filed together with th	ne international application in computer readable form.		
			ntly to this Authority in written form.		
		furnished subseque	ntly to this Authority in computer readable form.		
		The statement that the subsequently furnished written sequence listing does not go beyond the disclosu the international application as filed has been furnished.			
		The statement that the listing has been furn	he information recorded in computer readable form is identical to the written sequence ished.		
4.	The	amendments have r	esulted in the cancellation of:		
		the description,	pages:		
		the claims,	Nos.:		





International application No. PCT/GB00/03603

		the drawings,	sheets:
5.			established as if (some of) the amendments had not been made, since they have been ond the disclosure as filed (Rule 70.2(c)):
		(Any replacement sh report.)	eet containing such amendments must be referred to under item 1 and annexed to this
6.	Add	litional observations, i	necessary:
111.	Nor	n-establishment of o	pinion with regard to novelty, inventive step and industrial applicability
1.			e claimed invention appears to be novel, to involve an inventive step (to be non- ally applicable have not been examined in respect of:
		the entire international	al application.
	×	claims Nos. 22.	
be	caus	e:	
			application, or the said claims Nos. relate to the following subject matter which does tional preliminary examination (<i>specify</i>):
	⊠		s or drawings (<i>indicate particular elements below</i>) or said claims Nos. 22 are so unclear inion could be formed (<i>specify</i>):
		the claims, or said cla	ims Nos. are so inadequately supported by the description that no meaningful opinion
		no international searc	h report has been established for the said claims Nos
2.	and/	eaningful international or amino acid sequen uctions:	preliminary examination cannot be carried out due to the failure of the nucleotide ce listing to comply with the standard provided for in Annex C of the Administrative
		the written form has r	ot been furnished or does not comply with the standard.
			e form has not been furnished or does not comply with the standard.
			der Article 35(2) with regard to novelty, inventive step or industrial applicability;
	State	ement	
	Nove	elty (N)	Yes: Claims 1-21





International application No. PCT/GB00/03603

No:

Claims 23

Inventive step (IS)

Yes:

Claims

No:

Claims 1-21

Industrial applicability (IA)

Yes:

Claims 1-21,23

No: Claims

2. Citations and explanations see separate sheet

VII. Certain defects in the international application

The following defects in the form or contents of the international application have been noted: see separate sheet

VIII. Certain observations on the international application

The following observations on the clarity of the claims, description, and drawings or on the question whether the claims are fully supported by the description, are made: see separate sheet



Concerning Section III

The wording of claim 22 solely relies on a reference to the whole description, which results in a scope of the claim so unclear (Art. 6 PCT) that no meaningful opinion can be given.

Cf. also, in this respect, the Rule 6.2(a) PCT as well as PCT Guidelines, Chapter III, 4.10, which state that the claims must not rely on references to the description "except where absolutely necessary", which is presently not the case.

Concerning Section V

1. The documents (D) cited in the International search report will be referred to as D1 to D4 in the rest of the examination procedure, the numbering adopted corresponding to the order in which they are cited in this report.

Furthermore, the following additional document D5 (a photocopy of which is enclosed) is also considered relevant and is therefore introduced into the procedure by the Examiner:

- -D5: Sensors and Actuators A64 (1998), pages 33-39 (cited as reference [5] in D1)
- 2. The subject-matter of independent method claim 1 does not appear to involve an inventive step (Art. 33(3) PCT).

D3 (WO 99/09439 A) discloses (cf. in particular the Title and Abstract, as well as claim 1) a method of forming a photonic crystal material comprising exposing a photosensitive material to an interference pattern of electromagnetic radiation whereby the exposure through the material varies in accordance with the spatially varying intensity created by the interference to produce a three dimensional periodic variation in the refractive index of the photosensitive material based on the exposure.

The subject-matter of claim 1 therefore differs from the above prior art by the sole

WRITTEN OPINION SEPARATE SHEET



fact that the photosensitive material possesses an average number of crosslinkable groups per molecule of at least 3 with an equivalent weight per crosslinkable group of at most 1000.

However, it is already well-known in the art, in order to manufacture three dimensional (3-D) and/or thick structures, to use photosensitive materials such as the ultrathick com-mercial photoresist SU-8 [which SU-8 is described in the present application (cf. page 2, lines 16-22) as being constituted by glycidyl ether of bisphenol A novolac, which has an average of 8 epoxy groups per molecule and an equivalent weight per crosslinkable group of the order of 215]. Cf. in this respect, for instance D1 (Optics Letters, Vol.23, No.22, 1998, pages 1745-47), which discloses the use of SU-8 for manufacturing 3-D structures (cf. the Title and the Abstract, as well as page 1745, right col. beginning of last paragraph), and in particular 3-D photonic crystals (cf. page 1747, right col., eight lines before the end), on a voxel-by-voxel basis by IR two-photon exposure; or D2 (Journal of Vacuum Science and Technology B, Vol.13, No.6, 1995, pages 3012-16), which also discloses the use of SU-8 for manufacturing 3-D structures (cf. the Title and the Abstract, as well as page 3012, left col., Sect. I and II) by UV exposure; or D5, which also discloses the use of SU-8 for manufacturing thick structures by near UV-exposure (cf. in particular the Title and the Abstract, as well the point 2: "SU-8 resist properties and process").

It will therefore appear totally obvious to a skilled person in charge of manufacturing photonic crystals according to the method of D3 to decide to use in said method of D3, as an alternative to the photosensitive materials therein mentioned, the commercial photoresist SU-8 as disclosed in D1 or D2 or D5, which is known to be particularly appropriate to the manufacture of 3-dimensional and/or thick structures, thereby arriving directly at a method corresponding to that of claim 1.

3. Any argumentation aiming to demonstrate that SU-8 as disclosed in D1 or D2 or D5 is not suitable for the formation of holographic photonic crystal structures having uniform 3-D periodicity, because such formation requires precise conditions regarding the transparency, the solubility contrast and the latency of the material which are not met by said SU-8 as disclosed in D1 or D2 or D5, cannot be accepted for the different reasons as follows:

WRITTEN OPINION SEPARATE SHEET

- a) Regarding the high transparency required for the material: The transparency of SU-8 as disclosed in D1 or D2 or D5 firstly appears to be already relatively high, contrary to what could be argued. Cf. for instance D5, passage bridging the pages 33 and 34, where it is mentioned that "the key property (of SU-8) ...is its very low optical absorption in the near-UV range". D2 indeed mentions a transmission which is only of 46% at 365 nm, but for a 100 µm thickness, so that the transmission would be much more higher for layers with a thickness of the order of 10 to 30 µm as specified in the present application (cf. for instance page 7, line 26). Moreover, the skilled person in charge of forming a photonic crystal with the SU-8 material as disclosed in D1 or D2 or D5 will easily decide, if observing that the transparency of said material is not high enough at the used wavelength, to increase said transparency up to the right level, either by using a slightly higher wavelength as already taught by D3, page 15, lines 19-22 (it is furthermore very well known to the skilled person that the transparency of photosensisitve materials of the type of SU-8 increases with the wavelength, as shown for instance by the Fig. 1 of D2,), and/or by varying the concentration of the photo-acid generator relative to the epoxy precursor (and/or selecting a slightly different photo-acid generator). It must finally be noted that the photosensitive material as presently specified in claim 1 is not restricted to a predetermined range of transparency, which implies that any photosensitive material can in principle be used in the method of claim 1, provided it possesses an average number of crosslinkable groups per molecule of at least 3 with an equivalent weight per crosslinkable group of at most 1000, which is precisely the case of the SU-8 material as disclosed in D1 or D2 or D5;
- b) Regarding the high solubility contrast required for the material, it has to be noted that this property is, as argued by the Applicant and as mentioned in the pre-sent application (cf. page 2, lines 3-6), accentuated by selecting a resin with a very high crosslinking functionnality. This very high crosslinking functionnality is precisely also present in the SU-8 material as disclosed in D1 or D2 or D5, so that the use of such SU-8 material according to D1 or D2 or D8 in the method of D3 will also automatically and unavoidably result in the achieving of said property of high solubility contrast; and
- c) Regarding the latency which would be required for the material: It has to be noted that this property is apparently not essential in the present application, contrary to what is argued by the Applicant, since it is described in said application as



being given by the insertion of a photoacid generator (such as a triaryl sulfonium salt) in the material, which insertion of a photoacid grenerator is specified only in dependent claim 10, and not in independent claim 1. This property of latency is anyway also already known from D3, and it is disclosed therein as being also given by the insertion of a photoacid generator in the material (cf. page 14, lines 13-16 and 22-25). SU-8 as disclosed in D2 or D5 moreover also makes use of a photoacid generator such as a triaryl sulfonium salt (cf. Chap. II: "SU-8 properties and process", lines 2-4 as regards D2; or page 34, left col., lines 11-13 as regards D5), so that SU-8 as disclosed in said D2 or D5 has also unavoidably and automatically the desired latency properties.

4. The subject-matter of dependent claims 2 to 21 also does not appear to involve an inventive step.

The features of dependent claims 3 to 9 are also met by the photoresist SU-8 of D1 or D2 or D5.

D3 also discloses all the features of dependent claims 2, 10, 14, 15 and 17 to 21, i.e.,:

- -regarding claim 2: cf. claim 2 of D3;
- -regarding claims 10, 14 and 15: cf. page 14, lines 12-25;
- -regarding claims 17 to 19: cf. page 14, line 26 to page 15, line 14;
- -regarding claim 20: cf. page 7, lines 28-32:
- -regarding claim 21: cf. for instance page 5, lines 20-24.

The features of dependent claims 11 to 13 and 16 appear trivial to a person skilled in the art of photosensitive materials.

5. The subject-matter of independent product claim 23 does not appear to be novel (Art. 33(2) PCT).

Said claim 23, which is directed to an end-product defined solely by its manufacturing process has, independently of its lack of clarity as indicated in the Section VIII, point 4, thereafter, to be construed as a claim to the end-product <u>as such</u>. This means amongst other things that the features related to the manufacturing

WRITTEN OPINION SEPARATE SHEET



method are limitative only in the extent that they contribute to indirectly define some structural features of the end-product which are difficult to be defined in a direct manner. In other words, said features related to the manufacturing method do not limit the scope of the claimed end-product to the sole end-products as obtained with the specified method; the scope of such claim on the contrary also includes all the end-products obtainable by any other manufacturing method which is able to result in an end-product having the same structural features as those unavoidably resulting from the specified method [one of the consequences of such interpretation being that such claimed end-product is likely to be anticipated by any prior end-product which would present the same stuctural features, even if said prior end-product would have been manufactured by a different method (provided nevertheless that such different method leads to the same structural features for the end-product)].

The end-product as such according to said claim 23 (i.e. as it unavoidably stands, from the structural point of view, once the different steps of the manudfacturing method according to the claims 1 to 21 have been carried out) can as a matter of fact be structurally defined as consisting in a photonic crystal that has a 3-D periodicity in the refractive index, wherein the material which forms said photonic crystal can be any material, not even restricted to the specific photosensitive material as specified in the method of claim 1, since such specific material can, according to the following claim 19, be merely used provisionnally as a template, and then eliminated and replaced by any other material.

However, a number of photonic crystals with a 3-D periodicity in the refractive index are already known, which are made of various materials, so that claim 23 which includes such crystals has to be deemed to be not novel.

An amended claim 23, which would have been restricted to photonic crystals 6. made from the specific photosensitive material as specified in the method of claim 1, would have furthermore to be considered as involving no inventive step (Art. 33 (3) PCT), for the same reasons as those given in the above point 2 in relation with method claim 1.

WRITTEN OPINION SEPARATE SHEET



Concerning Section VII

- 1. Independent claim fails to follow the two-part form (Rule 6.3(b) PCT), which appears appropriate in the present case, and to be correctly delimited with respect to the nearest prior art D3 (cf. the analysis already made in the section V above).
- 2. The introductory part of the description fails (Rule 5.1(a) (ii) PCT) to aknowledge D1, D2 and D5, with a detailed analysis of their relevant content (cf. the analysis as already made in the Section V above).

Concerning Section VIII

The original set of claims 1 to 21 and 23 does not meet the clarity requirements of Article 6 PCT as regards at least the following points:

- 1. Claim 1 should have specified that the interference pattern generated in the photosensitive material is a three dimesnsional interference pattern, so to enable to understand how a "spatially" varying intensity can be created by said interference and how a 3-D periodic variation in the refractive index (as specified on lines 4 and 5 of claim 1) can be achieved, as well as to give an antecedent to the expression "the 3-D pattern" in dependent claim 21.
- 2. Dependent claim 14 should have been appended to claim 10 and following (instead of claim 1 and following as presently), taking into account that the forming of an acid catalysed polymerisation necessitates the presence of an acid generator, as only specified in claim 10.
- 3. Likewise, dependent claim 17 should have been appended to claim 2 and following (instead of claim 1 and following as presently), taking into account that the development step as well as the voids resuting from such development are only specified in claim 2.
- 4. Independent claim 23 leaves a strong doubt as to its category in that, whereas it is in principle directed to an <u>end-product</u> (i.e. "a photonic crystal material"), it defines

WRITTEN OPINION SEPARATE SHEET



in fact said end-product solely by its <u>method of manufacturing</u> [cf. the expression "wherever formed by the method as claimed in any one of the preceding claims"], which manufacturing method is furthermore <u>no longer visible</u> on the end-product once it has been completely manufactured.

In a general manner, an end-product (or one of its constitutive elements) as to be defined as mostly as possible by its structural features so as to avoid a lack of clarity (and in particular to remove any doubt as to the category of the claim). The complementary or sole characterisation of an end-product (or one of its constitutive elements) by its process of manufacturing is possibly acceptable solely for clearly defining in an indirect manner those of the structural features which are hardly specifiable as such in an adequate manner, which does not appear to be the case presently (cf. for instance the Section V, point 5, 2nd paragraph, thereabove, showing that the photonic crystal can be entirely defined in term of structural features).

Moreover, when an end-product (or one of its constitutive elements) has to be (at least partly) characterised by its process of manufacture, such characterisation should then take the form "end-product (or element) <u>obtainable</u> by said process" rather than "end-product (or element) formed by said process" as specified presently, in order to remove any doubt as to the category of the claim.
